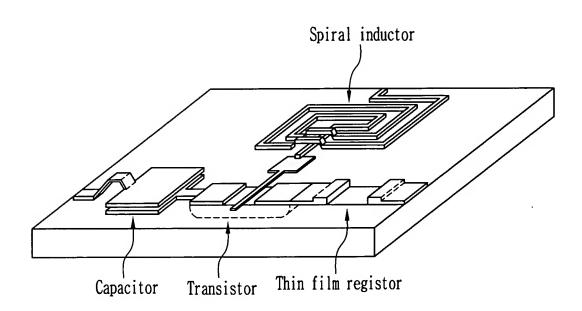
29936/39864 Kyeong Keun Choi METHOD FOR FORMING HIGH RESISTIVE REGION IN SEMICONDUCTOR DEVICE Sheet 1 of 3

## FIG. 1 (PRIOR ART)



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